

Employing Cathodoluminescence for Nanothermometry and Thermal Transport Measurements in Semiconductor Nanowires

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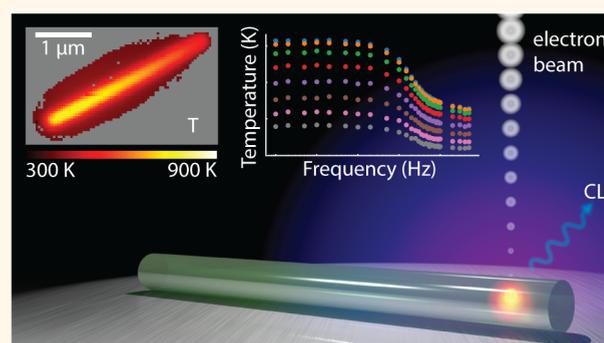
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ABSTRACT: Thermal properties have an outsized impact on efficiency and sensitivity of devices with nanoscale structures, such as in integrated electronic circuits. A number of thermal conductivity measurements for semiconductor nanostructures exist, but are hindered by the diffraction limit of light, the need for transducer layers, the slow scan rate of probes, ultrathin sample requirements, or extensive fabrication. Here, we overcome these limitations by extracting nanoscale temperature maps from measurements of bandgap cathodoluminescence in GaN nanowires of <300 nm diameter with spatial resolution limited by the electron cascade. We use this thermometry method in three ways to determine the thermal conductivities of the nanowires in the range of 19–68 W/m·K, well below that of bulk GaN. The electron beam acts simultaneously as a temperature probe and as a controlled delta-function-like heat source to measure thermal conductivities using steady-state methods, and we introduce a frequency-domain method using pulsed electron beam excitation. The different thermal conductivity measurements we explore agree within error in uniformly doped wires. We show feasible methods for rapid, *in situ*, high-resolution thermal property measurements of integrated circuits and semiconductor nanodevices and enable electron-beam-based nanoscale phonon transport studies.

KEYWORDS: cathodoluminescence thermometry, nanothermometry, thermal transport, thermal conductivity, gallium nitride nanowire, semiconductor nanowire, cathodoluminescence



Highly concentrated energy densities and fewer thermal conduction pathways through which waste heat dissipates can lead to substantially elevated temperatures and thereby reduced performance in nanodevices. Temperature control is crucial in many systems: nanowire single-photon detectors must be cryogenically cooled to enter the superconducting regime and eliminate thermal noise;¹ nanowire lasers see a shift in lasing threshold and wavelength with temperature rises;² thermoelectric nanostructures rely on low thermal conductivity to generate large temperature gradients to increase efficiency of power generation or detection;³ and a microchip can have significantly varying gain and noise characteristics across its range of operating temperatures. Additionally, as integrated circuits shrink in size, the on-chip power density has increased by an order of magnitude over a decade, creating challenges in how to handle heat dissipation in nanoscale transistors.⁴ Therefore, careful design of thermal management in nanostructure devices is critical to provide stable output and

performance, as these technologies increasingly move to smaller scales. Past research has studied engineering thermal conductivity by measuring or tailoring phonon mean free path spectra.^{5–13} However, measuring both temperature and thermal conductivity of nanostructures is notoriously difficult.

A number of noninvasive methods have been devised to measure temperature and thermal conductivity on the nanoscale.^{14–17} The highest spatial resolution thermometry methods include near-field scanning optical microscopy,^{18,19} scanning thermal microscopy,^{20,21} and transmission electron microscopy.^{22–24} These methods can have a spatial resolution

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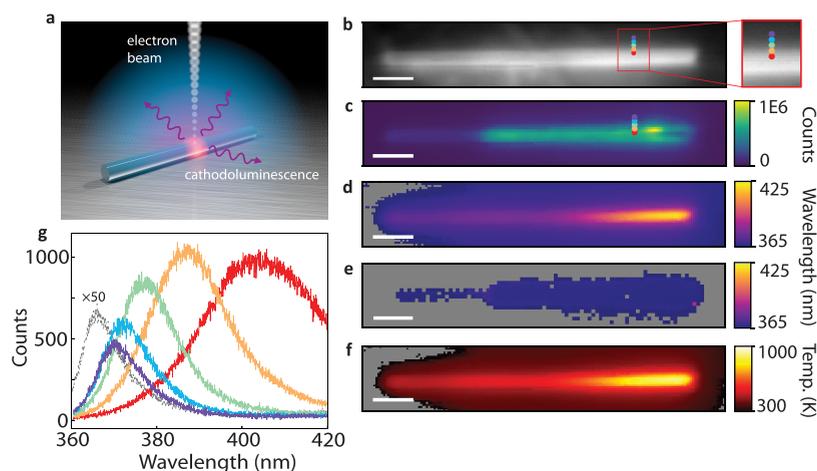


Figure 1. Nanoscale thermometry CL measurement technique and monitored signals. (a) Schematic of cathodoluminescence (CL) measurements on a semiconductor nanowire. An electron beam heats/excites the semiconductor nanowire, and incoherent CL is collected by the high-numerical-aperture parabolic mirror and directed into a spectrometer. (b) SEM image (210 nA 5 keV electron beam) of a GaN nanowire taken simultaneously with CL data. (Inset) Zoomed-in region of a GaN wire. (c) CL counts integrated between the wavelengths of 360–420 nm. (d, e) Peak CL wavelength extracted by fitting the spectra corresponding to each pixel with a Lorentzian for experiments performed with an electron beam current of 210 nA (d) or 1.6 nA (e). Gray regions were pixels with peaks of less than 10 counts. (f) Temperature map measured when the electron beam (210 nA) is focused at each pixel, obtained by fitting the data in (d) to eq 1. (g) CL spectra. Each spectrum is obtained at the position of the corresponding color dot in both (b) and (c). The amount of spatial overlap of the electron beam and the nanowire dictates the energy absorbed in the nanowire from the electron beam, resulting when the beam is centered on the nanowire, in a maximum temperature rise and corresponding red-shift of the CL emission according to eq 1. The gray curve corresponds to CL taken from a 1.6 nA electron beam at the location of the red dot (using a 50× longer exposure time), and the other curves were taken with a 210 nA electron beam. Scale bars are 500 nm.

well below 100 nm but have generally slow data collection or cumbersome probes or require very thin samples. Common thermal conductivity measurement methods include the 3ω method,^{25,26} the suspended microchip method,^{27–29} and time-domain thermoreflectance^{8,9,13,30–33} and its variants.³³ These methods lack the spatial resolution of the high-resolution thermometry methods listed above and require invasive or extensive fabrication or a transducer layer, all of which hinders the ability to measure smaller domains or thermal boundary effects.^{31,33}

Here we demonstrate a rapid, high-resolution solution for measuring temperature and the thermal conductivity of nanostructures using cathodoluminescence (CL) spectroscopy. CL is radiation emitted when a high-energy electron beam (e.g., in a scanning electron microscope (SEM) or transmission electron microscope) interacts with a material. In semiconductors, CL derives primarily from bandgap emission generated when high-energy electrons lose energy to bulk plasmons through inelastic collisions, which then excite hot electron hole pairs, which can thermalize and/or generate electron hole pairs that subsequently recombine by the emission of CL.^{34–36} CL spectroscopy has been used in mineralogy,³⁷ semiconductor characterization,^{38,39} and the study of plasmonic and photonic modes in metallic or dielectric nanostructures with nanometer resolution.^{40,41} As we will show, at low beam currents, CL thermometry provides high-resolution noninvasive temperature measurements. At high beam currents, the beam acts like a nearly delta function heat source while simultaneously probing the temperature. CL has seldom been used for thermometry,^{42,43} and it has not, to our knowledge, been used for nanoscale thermal imaging or to study thermal conductivity. In our method of CL thermometry, the spatial resolution is limited primarily by the electron beam cascade size in the material, which can be in the range of

about 1–200 nm depending on the electron energy, and also by the electron probe size and the minority carrier diffusion length.⁴⁴ We apply this technique to study the thermal conductivity of GaN nanowires, which are of increased interest due to their promise for optoelectronic applications^{45,46} including nanowire lasers.^{47–49}

First, with the spatial resolution of an SEM cascade, we use the thermal bandgap shift in semiconductors to map out the temperature profile from an electron-beam-induced heat source in a nondestructive manner, measuring electron-beam-induced temperature rises of over 500 K. Next, we use this thermometry technique to extract the thermal conductivity of GaN nanowires with three different methods: two methods using a DC electron beam current, and one method using a technique involving an ultrafast electron beam blaster to provide an AC heating/thermometry source. The data obtained using the three methods is comparable in finding that the GaN nanowires exhibit a thermal conductivity lower than that of bulk GaN. With higher spatial resolution than state-of-the-art laser-based techniques³² combined with fast scan speeds, variable probing/heating depth, and no near-field probe or thin sample requirement, our work enables nanoscale phononic and thermal transport studies in semiconductors, including *in situ* measurements of silicon-integrated circuits.

RESULTS AND DISCUSSION

Temperature Measurements. The concept of CL is shown in Figure 1a, and the CL setup used is described further in previous work.⁵⁰ Briefly, a parabolic mirror inside of the SEM chamber with a numerical aperture of 1.46π sr is aligned over the sample so that the focal point of the mirror corresponds to the electron beam focus on the sample, and light is then collected and directed to a spectrometer. An SEM image of one of the GaN nanowires used is shown in Figure

1b. The 200–300 nm diameter GaN nanowires were made by a top-down approach based on sublimation under vacuum (see [Methods](#)) and exhibit lasing properties⁴⁹ under optical pumping. We observe that the nanowires continue lasing while simultaneously undergoing high current electron beam irradiation indicating negligible degradation of the wires during CL measurements (see [Figure S1](#) for more details). The nanowire was broken off the substrate on which it was grown and placed on the frame of a copper TEM grid covered with a 2 nm thickness of lacey carbon film, which thermally isolates the wire relatively well. [Figure 1c](#) shows a CL intensity map of the wire for emission between 360 and 420 nm, and the corresponding SEM image (collected during CL imaging) is shown in [Figure 1b](#) taken at a beam current of 210 nA and electron energy of 5 keV. At each pixel in the CL map, the electron beam is focused at this point, and light is collected and the spectrum analyzed. [Figure 1g](#) illustrates a red-shift in the peak bandgap emission of the CL spectrum as the electron beam becomes more centered on the wire, which we will explain shortly, and the color of the spectra in [Figure 1g](#) corresponds to the location of the colored dots on [Figure 1b,c](#) (the gray curve is CL from a lower current 1.6 nA beam at the location of the red dot). The small, non-red-shifted CL peak observed for the beam placed next to the wire results from either backscattered or secondary electrons from the substrate, which excite CL from the wire and deposit little power inside, or stray electrons from an enlarged electron beam. The most intense and most red-shifted CL is observed for a high-current electron beam centered on the wire. Using CASINO⁵¹ Monte Carlo simulations, we determine that approximately 71% of the energy of the electrons is converted to heat in the wire. The remainder of the electron beam energy is mostly lost to backscattered and secondary electrons ([Figure S2](#)), with a negligible amount of energy lost to bandgap emission ([Figure S3](#)) and X-rays. Electron beam heating^{52–55} calculations based on CASINO Monte Carlo simulations have previously been verified experimentally.^{52,53} With a 210 nA electron beam, this corresponds to 746 μW of power being deposited in the wire in a nearly delta-function-shaped power distribution (see [Figure S2](#)).

Our thermometry is carried out by tracking the shift in the peak bandgap emission energy as a function of temperature, due to thermal expansion of the lattice and changes in electron–phonon interactions with temperature.^{56,57} As shown in [Figure S4](#), we calibrate the wavelength shift with temperature in our GaN nanowires by measuring the bandgap shift as a function of temperature between 90 and 300 K using a 548 pA beam current in a liquid-nitrogen-cooled cryogenic stage on our microscope. At a beam current this low the heating induced by the electron is negligible. While GaN shows a bandgap shift at room temperature and higher, many of our measurements were carried out below room temperature within the range of our calibration curve to ensure our measurements were accurate (we did not have a heating stage available for calibration); in some cases we extrapolate this curve to higher temperatures, following the Varshni phenomenological formula,⁵⁷

$$E_g(T) = E_g(0) - \frac{\gamma T^2}{\beta + T} \quad (1)$$

where E_g is the bandgap as a function of temperature, T , $E_g(0)$ is the bandgap energy at 0 K (a fit parameter), and γ and β are

constants.⁵⁷ The bandgap shift could alternatively be fit to an expression from O'Donnell and Chen.⁵⁶ While we focus on CL thermal measurements in GaN in this paper, a bandgap shift (red or blue) with increasing temperature can be seen in many other semiconductor materials;^{56,57} CL spectra for intrinsic GaAs and p-doped Si wafers at different temperatures are shown in [Figure S4](#) to demonstrate that the CL thermometry and the thermal conductivity measurement techniques presented here are not limited to use with GaN. Photoluminescence bandgap shifts in GaN nanowires have previously been used to measure temperature in a similar manner, but suffer from the poor resolution of the laser used as a heater/probe.⁵⁸

From our fit ([Figure S4](#)), we determined $E_g(0) = 3.471$ eV (in GaN this corresponds to a donor-bound excitonic transition at low temperature, not the bandgap⁵⁹), $\beta = 2609$ K, and $\gamma = 2.25 \times 10^{-3}$ eV/K, which is similar to previous studies of GaN epilayers on sapphire substrates,⁵⁹ with differences likely caused by different growth mechanism and the nanoscale geometries, and the fact that we fit a single Lorentzian to the entire near-band-edge PL spectrum to determine our effective bandgap instead of tracking shifts of individual exciton transitions the PL spectrum is composed of. The root-mean-square error in temperature of our data around the line of best fit is 6.0 K, which was measured in a region of fairly uniform doping. The thermal stage used had a temperature accuracy of ± 1 K, and additional error likely comes from small doping variations within the region measured. Larger errors in temperature will arise in regions of dissimilar doping, which can be corrected for and will be discussed later. We fit the data in [Figure 1d](#) with [eq 1](#) to create a temperature map ([Figure 1f](#)) of the GaN nanowire resulting from electron beam heating at each pixel.

In order to reduce uncertainty in the thermal contact area between the wires and the substrate, nanowires were scattered over a copper TEM grid (Ted Pella G2000HA) with 6.5 μm diameter holes. Wires that straddled holes were heat sunk to the copper *via* electron beam assisted Pt deposition to fix the temperature at the ends of the wires during heating and reduce interfacial thermal resistance between the wires and the Cu TEM grid.²⁸ An SEM image of a wire in this configuration is shown in [Figure 2a](#). Following previous work,^{27–29,52–55,58,60,61} we treat the nanowires as 1D systems and ignore thermal radiation and losses from CL (see [Figure S3](#)) in our analytical calculations. Finite element⁶² simulations support this approximation. [Figure 2b–e](#) show temperature maps of the wire in [Figure 2a](#) for different electron beam currents, in which the electron beam itself is used both as a heat source and as a thermometer. In these maps, the sample stage temperature was maintained at 161 K, and the peak CL wavelength was extracted for each pixel on the map and converted to temperature according to our calibration curve ([eq 1](#)). Note that each pixel is measured when the electron beam is focused on that particular location. We use a 5 keV electron beam, as Monte Carlo simulations indicate that at this energy most of the electron energy will be deposited within the wire ([Figure S2](#)). A higher energy beam would give better spatial resolution, but most of the electrons would pass through the wire without interacting, decreasing heat deposition.

Several trends can be observed from the data in [Figure 2](#). First, in all images the largest temperature rise is observed toward the center of the wire, as expected theoretically for a 1D system with fixed temperature at both boundaries and an

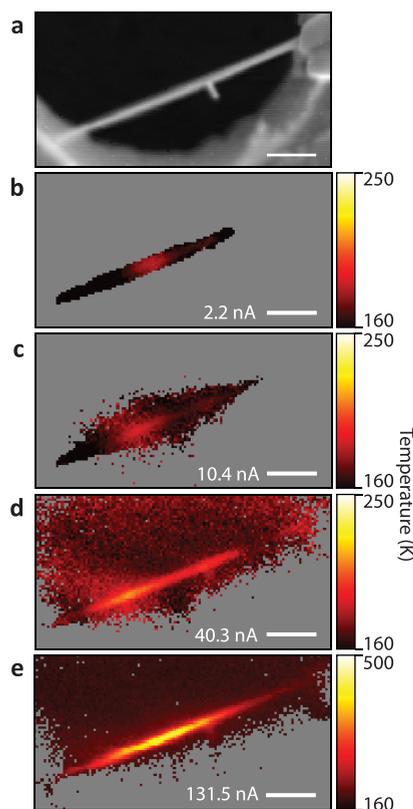


Figure 2. Nanoscale temperature measurements at variable electron beam currents. (a) SEM of suspended GaN nanowire with Pt heat sinks on either end. (b–e) Temperature measurements of a GaN nanowire at the specified electron currents. Gray regions indicate pixels that did not exhibit a peak in the CL spectrum above 100 counts and 1 nm in width or which could not be fit. Scale bars are 1 μm . The base temperature in all measurements is 161 K.

internal heat source. We can also see the high spatial resolution of the CL thermometry technique. Using higher beam currents we can generate temperature increases of over 200 K, showing the power of this technique to create temperature profiles from which the thermal conductivity can be derived, as we will show below. The CL from this wire was comparatively weak (possibly due to either the doping level or increased surface recombination velocity from carbon deposition), so a measurement with low enough current to create a nonheated background measurement was not possible. In order to produce the large currents in Figure 2c–e, a large 1 mm

aperture in the SEM column was used, which blocked fewer astigmatic electrons and created a misshapen electron beam. This decreased resolution meant that when the majority of the electron beam was focused on a pixel in the hole of the TEM grid, some stray electrons were still striking the wire. Different electron beam focusing settings (spots) were used to generate different currents, which likely caused the hot spot in the center of the wire to shift slightly. Figure 2b used the same electron beam focusing settings as in Figure 2e, but used a 100 μm aperture.

DC Thermal Conductivity Measurements. We demonstrate three different methods to derive the thermal conductivity from the CL profiles, the first two being DC measurements, with analysis similar to Raman thermography or photoluminescence mapping found in other work.^{58,60,61} In the DC measurement techniques, the wire is suspended over a hole in the TEM grid as shown in Figure 2a and Figure 3g and heated by a continuous electron beam, and the steady-state temperature is extracted at every point along the wire as shown in Figure 3a,b. We fit the temperature profile using theoretical models for 1D wires with the temperature fixed by heat sinking with SEM-deposited Pt at both ends (the bridge method, Figure 3c) or at one end (the slope method, Figure 3e). In the bridge method, thermal contact resistance between the GaN and Cu TEM grid must be negligible,⁶¹ and in the slope method this thermal contact resistance is not important.⁶⁰

In the DC bridge method, both ends of the nanowire are heat sunk with SEM-deposited Pt and suspended over a bare copper TEM grid hole (see inset of Figure 3a,g). We form an equivalent resistance model for the wire (described in more detail in a [Supplementary Note](#)), shown in Figure 3d, similar to previous work.⁶¹ We assume there are two different thermal conductivities in the system: the thermal conductivity of GaN in the center of the wire, κ_{GaN} , and an effective thermal conductivity for a mixture of GaN and Pt closer to the Pt heat sinks, κ_0 , attributed to the enlarged GaN nanowire radius due to excess Pt on the surface (see Figure S5, Figure 3c). L_1 and L_2 demarcate the boundaries between the regions of different thermal conductivities and were treated as fit parameters. The system is represented in Figure 3d by a thermal circuit model. Here, the thermal resistance is given by $R = lA/\kappa$, with l being the relevant length of the particular segment and κ the thermal conductivity of that segment. l can change depending on the position of the heat source (see Figure 3c, [Supplementary Note](#)), so the equations for the peak temperature rise, $\Delta T(x)$, as a function of x , the position of the electron beam heat source/thermometer, are

$$\begin{aligned} \Delta T(x) &= \frac{\dot{Q}}{A} \left(\frac{\kappa_0}{x} + \frac{\kappa_0 \kappa_{\text{GaN}}}{\kappa_{\text{GaN}}(L_1 - x + L - L_2) + \kappa_0(L_2 - L_1)} \right)^{-1}, \quad 0 \leq x \leq L_1 \\ \Delta T(x) &= \frac{\dot{Q}}{A \kappa_0 \kappa_{\text{GaN}}} \left(\frac{1}{\kappa_{\text{GaN}} L_1 + \kappa_0(x - L_1)} + \frac{1}{\kappa_0(L_2 - L_1) + \kappa_{\text{GaN}}(L - L_2)} \right)^{-1}, \quad L_1 \leq x \leq L_2 \\ \Delta T(x) &= \frac{\dot{Q}}{A} \left(\frac{\kappa_0 \kappa_{\text{GaN}}}{\kappa_{\text{GaN}}(L_1 + x - L_2) + \kappa_0(L_2 - L_1)} + \frac{\kappa_0}{L - x} \right)^{-1}, \quad L_2 \leq x \leq L \end{aligned} \quad (2)$$

where \dot{Q} is the heat flux from the electron beam, L is the total wire length, A is the cross-sectional area of the wire as measured *via* SEM images, and $\Delta T(x) = T(x) - T_0$, where T_0

is the fixed temperature at $x = 0$ and $x = L$. Figure 3c shows this geometry in more detail. We fit temperature data obtained in Figure 2e with eq 2 in order to extract κ_{GaN} , κ_0 , L_1 , and L_2 .

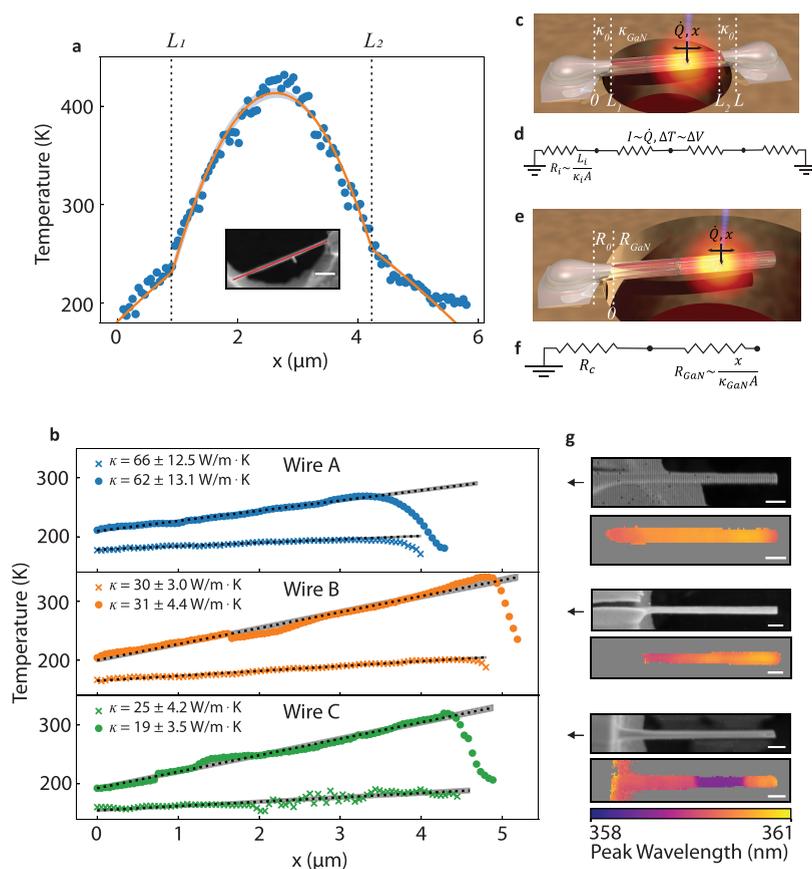


Figure 3. Probing nanowire thermal conductivity with a DC electron beam. (a) Measured temperature as a function of position along the cut through the GaN wire from Figure 2a (shown in the inset). Orange line is best fit to data using eq 2 (DC bridge method), and blue shading is 1 standard deviation of the fit error. We find a thermal conductivity of the GaN nanowire of 22 ± 4.7 W/m \cdot K and of the Pt/GaN portion 91 ± 18.9 W/m \cdot K. Base temperature for these measurements is 161 K. Wire radius is 118 nm. (b) Demonstration of DC slope method for determining thermal conductivity of two different nanowires with fixed temperature at one end. “O” data points are from data collected with 1 mm apertured electron beams, which result in a less well-defined spot size. The “X” data points are from 100 μ m apertured electron beams, which result in a less well-defined spot size. The corresponding thermal conductivities are shown in the legends. Radius of the nanowires is 130 ± 11.8 , 123 ± 5.8 , and 142 ± 11.4 nm for wires A, B, and C, respectively. (c) Schematic of temperature profile in the wire corresponding to the DC bridge method and values in eq 2. (d) Thermal circuit model for the DC bridge method, shown here for the case of $L_1 \leq x \leq L_2$, where x is the location of the electron beam (see Supplementary Note for more details). (e) Schematic of the temperature profile in the wire corresponding to the DC slope method and values in eq 3. (f) Thermal circuit model for the DC slope method. (g) SEM and peak wavelength map for each wire in the plot on the left. The peak wavelength is measured with an electron beam current of 1 nA to extract the doping variation without significantly heating the nanowire. The wavelength shift due to doping was subtracted from wavelength shifts due to heating to produce the curves in (b); see Supplementary Figure S6. The apparent crack in the Pt in the SEM images is due to Pt being deposited at an angle to ensure good thermal contact between the wire and Cu below by filling gaps on one side of the wire. Scale bars are 500 nm.

This fit is shown with the data in Figure 3a. We find the thermal conductivity of the GaN region to be $\kappa_{\text{GaN}} = 22 \pm 4.7$ W/m \cdot K and the thermal conductivity of the edge region to be $\kappa_0 = 91 \pm 18.9$ W/m \cdot K.

Several factors affect the accuracy of the determination of the parameters in the DC bridge method. First of all, our calibration curve only extends up to room temperature, while we extrapolate above room temperature in this analysis, creating some uncertainty. In future work this can be avoided by performing a more extended calibration. Second, a small variation in doping within each nanowire causes a ~ 1 nm variation in CL peak energy in different places along the wire (CL variation due to doping has also been observed previously in GaAs nanowires³⁹), which also affects the temperature calibration. This could be corrected for by using, as a reference, low-current CL measurements that probe the bandgap at each position, as we do later. Here we use a relatively high beam current to create a fairly high temperature rise to more

effectively smooth out the 1 nm variations in CL peak shift along the wire (since spectral peak shifts in this measurement are much larger than 1 nm). Because we heat sink both ends of the wire, a relatively high current is needed to achieve a large red-shift. We note that in most of our nanowires a 1–2 μ m region at one end shows both less CL intensity (see Figure 1c) and a slightly blue-shifted CL peak relative to the rest of the nanowire (measured at low electron beam currents), while toward the other end of the wire an abrupt increase in CL counts with a slight red-shift is observed. This is due to the doping profile introduced during nanowire growth (see Methods). We note that in the DC bridge model we neglect the interfacial thermal resistance⁶¹ between the GaN and the Pt/Cu at either end, as it is small compared to the thermal resistance of GaN, which we verify with our measurements by ensuring temperature rises are very small near the Cu heat sinks, as seen in Figure 3a. The interfacial thermal resistance is not always negligible between the end of the wire and the Cu

substrate, which we observe in our measurements as a discontinuity between the temperature of the nanowire near the Cu and the Cu temperature, known from a thermometer in the sample stage (within 1 K accuracy) to which the Cu is thermally connected with silver paint. To overcome this, a different method can be used to measure thermal conductivity, the DC slope method.⁶⁰

In the DC slope method, only one end of the wire is heat sunk (see Figure 3g) and the other end extends into the center of the hole. In this method,⁶⁰ the temperature rise when the electron beam is at position x away from the edge of the hole (Figure 3e) is given by

$$\Delta T(x) = \left(R_c + \frac{x}{A\kappa_{\text{GaN}}} \right) \dot{Q} \quad (3)$$

where R_c is thermal contact resistance between the wire and the Cu frame. If we find the slope, s , of this line, $d\Delta T/dx$, and solve for κ_{GaN} , we find the expression $\kappa_{\text{GaN}} = \dot{Q}/(sA)$. We determine A (wire cross-sectional area) from SEM images. \dot{Q} (heat flux) we determine from the measured electron beam current correcting for energy lost to backscattered or secondary electrons (determined from CASINO Monte Carlo simulations). In the case of the “O” data points in Figure 3b, we also correct for larger electron beam sizes that resulted as a consequence of using large currents. The slope is found by fitting a line to the temperature profile of the wire sufficiently far from the Pt contacts to avoid the effect of the Pt/GaN thermal conductivity seen in Figure 3a. We additionally subtract the doping profile (resulting from variations in intentional Si-doping during growth) of the wires found under low electron beam current³⁹ shown in Figure 3g to correct for the ~ 1 nm doping variations along the wire as discussed above (see Figure S6, Methods). The profiles of three such wires are shown in Figure 3b with thermal conductivities specified in the figure caption, ranging from 19 to 66 W/m·K with errors ranging from 10% to 21%, which derive primarily from uncertainty in A due to small variations in diameter along the length of the wire and, in the case of the “O” data points, from a 10% error in \dot{Q} , as discussed below.

The benefit of the DC slope method over the DC bridge method lies in the ability to neglect thermal contact resistances. Additionally, larger temperatures can generally be reached in wires only thermally connected on one end. Overall, DC methods suffer from strong dependence on localized doping variations. This can be overcome by extracting bandgap variations due to doping profiles with low electron beam currents, as was done in Figure 3b. Because both doping concentration and temperature changes cause bandgap variations, the effect of each must be determined separately. By measuring the bandgap without heating the nanowire, we can determine the bandgap variations due to doping concentrations. In these particular nanowires, the doping variations are significant. If doping is neglected, one could improperly extract a negative value for thermal conductivity from uncorrected wire C thermal profile data in Supplementary Figure 6 due to a negative slope (eq 3). There is additional uncertainty that comes from the heat flux in the wire, in the case of Figure 3a and “O” data points in Figure 3b. Because large currents are needed to raise temperatures for good signal-to-noise ratio, larger apertures must be used in the electron column, which leads to larger spot sizes.⁶³ This is generally negligible in comparison to the size of the electron cascade,

unless a large (e.g. 1 mm) aperture is used and less of the incident electron beam impinges upon the wire, adding some uncertainty to the measurements of the heat flux \dot{Q} . In the measurements of Figure 3a and b (“O” data points only), by examining the loss of resolution in secondary electron images as a result of increased electron beam size, we calculate that only approximately 20–50% of the electron beam is reaching the nanowire without an aperture. Thus, the current actually reaching the nanowires was 64.0 nA for Figure 3a, and for Figure 3b wires A, B, and C “O” data points were 15.7, 11.0, and 9.3 nA, respectively. To double-check the veracity of our thermal conductivity measurements using the DC slope method, an aperture was used when collecting the “X” data points in Figure 3b, leading to less current (5.6, 3.2, and 3.2 nA for wires A, B, and C, respectively), a smaller temperature rise in the wire, but all of the measured electron beam current striking the wire in a several-nanometer-sized spot. The dependence on knowing \dot{Q} to a high degree of accuracy can be overcome by using AC methods to extract thermal conductivity, as discussed in the next session.

AC Thermal Conductivity Measurements. In the AC thermal conductivity measurement technique, the column of the SEM was equipped⁶⁴ with a high-frequency electrostatic beam blaster to modulate the electron current in a square wave on/off pattern. The sample configuration is the same as that used in the DC slope method described above, in which one end of the nanowire is heat sunk with SEM-deposited Pt and the other end is free (Figure 3g). In this method, we focus the electron beam on the free end of the wire for the duration of the experiment and vary the electron beam current frequency with a waveform generator between 100 Hz and 5 MHz (Figure S7). Data collection for the studied frequency range took several minutes total. Solving the 1D time-dependent heat equation (using one Dirichlet and one time-dependent-periodic Neumann boundary condition) for the quasi-steady-state temperature (after all transients have subsided) at the free end of the nanowire, temperature varies according to the expression (see Supplementary Note for more details)

$$T(\omega, t) = T_0 + \frac{4\dot{Q}L}{A\kappa\pi} \times \left(1 + \text{Re} \left\{ \sum_{m=1,3,5,\dots}^{\infty} \frac{x}{Lmi} \frac{\tanh\left(\sqrt{\frac{\omega L^2 C_p \rho m}{2\kappa}}(1+i)\right)}{\sqrt{\frac{\omega L^2 C_p \rho m}{2\kappa}}(1+i)} e^{im\omega t} \right\} \right) \quad (4)$$

where T_0 is the temperature of the fixed end/Cu frame, A is wire cross-sectional area, κ is the thermal conductivity (we assume uniform thermal conductivity in the wire), ρ is the density of GaN⁶⁵ (6150 kg/m³), C_p is the heat capacity⁶⁵ (490 J/kg·K), and L is the wire length starting from the edge of the Pt deposition. Because we use a spectrometer with a long exposure time (40 ms or longer) compared to the modulation frequency of the beam, we measure the average temperature over the half period when the electron beam is on (Figure 4b),

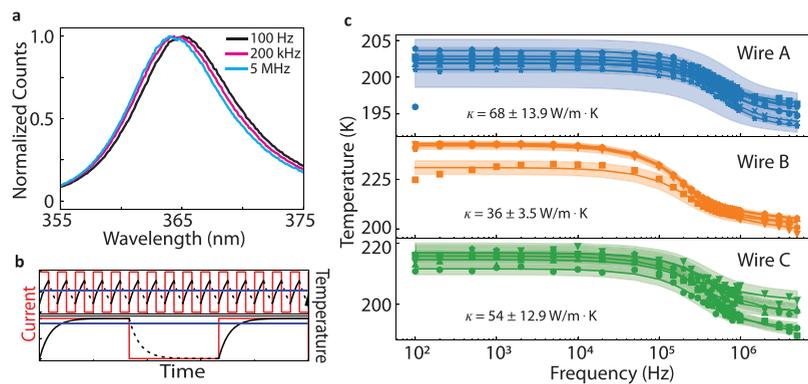


Figure 4. Cathodoluminescence thermal conductivity measurements in the frequency domain. (a) Cathodoluminescence (CL) spectra as a function of wavelength for a 100 Hz (black), 200 kHz (pink), and 5 MHz (blue) square wave electron beam excitation current. The electron beam current used in this measurement to heat/probe the nanowire was 42 nA DC (the current measurement was taken without modulation; with modulation the DC measured current is half that value). (b) CL is only emitted when electron current (red) is flowing, so the temperature read by CL (black, solid line) will be on average (blue) higher for lower frequencies. (c) Temperature as a function of electron beam square wave frequency for the same wires from Figure 3b,g with one end held at a fixed temperature. Each plot shows several different data collection runs (represented by different marker types) for the same wire at slightly different locations on the end of the wire. The solid line is the best fit line to the data, and the shaded regions are 1 standard deviation of error in the fitting function. The extracted thermal conductivities are shown in each plot. Error is a combination of standard deviation of thermal conductivity extracted from plot data and percent error in measurement due to uncertainty in length measurements. The electron beam current used in this measurement to heat/probe the nanowire was 18, 29, and 29 nA DC for wires A, B, and C, respectively (the current measurement was taken without modulation; with modulation the DC measured current is half the given value).

$$\bar{T}_{\text{meas}}(\omega) = T_0 + \frac{4\dot{Q}L}{Ak\pi} \times \left(1 + \frac{2}{\pi} \text{Re} \left\{ \sum_{m=1,3,5,\dots}^{\infty} \frac{1}{m^2} \frac{\tanh\left(\sqrt{\frac{\omega L^2 C_p \rho m}{2\kappa}} (1+i)\right)}{\sqrt{\frac{\omega L^2 C_p \rho m}{2\kappa}} (1+i)} \right\} \right) \quad (5)$$

The sum arises from the Fourier decomposition of a square wave. We find that at low modulation frequencies (e.g., 100 Hz) the time-averaged temperature of the GaN wire is higher, and therefore it has a more red-shifted CL spectrum than at higher frequencies (e.g., 5 MHz), as shown in Figure 4a.

Wavelength spectra for each modulation frequency were fit to extract the temperature data shown for three different wires in Figure 4c, the same wires of which were analyzed in Figure 3b using the DC slope method. Several different frequency sweeps were performed for each wire at slightly different locations at the end of the wires, which correspond to the different fit curves in Figure 4c. The solid lines are fits corresponding to eq 5. The error in thermal conductivity due to the variation in thermal conductivity extracted from the fit of each curve in Figure 4c is approximately 4.1%, 6.6%, and 14% for wires A, B, and C respectively. The mean value of L was taken from data from the DC slope method (i.e., where a kink in slope of temperature *versus* x appears, indicating Pt deposition, not shown in Figure 3d but visible in Figure 3a), and uncertainty was measured as the range of the visible thickening of the nanowire radius due to leakage Pt deposition, as seen in SEM images. Uncertainty in L ranges from 5% to 10% for the wires. This leads to an uncertainty in thermal conductivity due only to contributions from L uncertainty of 20%, 7.5%, and 20% for wires A, B, and C, respectively. Thus, uncertainty in the AC method thermal conductivity measurements has the largest contribution from L uncertainty. The leakage of Pt deposition onto the wires was the primary culprit for this uncertainty, as it is unclear where the exact location of

the “fixed” temperature end of the wires is. The uncertainties can be strongly reduced by further control over the sample geometry. The DC slope method does not rely on knowledge of L to extract thermal conductivity, and the DC bridge method treats the equivalent of L as a fit parameter, incorporating error into the fit model.

As the incident current decreases, the average temperature will decrease across all electron beam modulation frequencies, until the current heats the wire below the error of the temperature measurement precision, giving a flat line. Supplementary Figure 8 explores this effect by focusing the electron beam off-center of the nanowire, thereby depositing less power into the nanowire. We see consistent thermal conductivities measured at different deposited powers.

The benefit of the AC method is that the value of the electron beam heat flux, \dot{Q} , does not need to be known in order to extract thermal conductivity, unlike in the DC methods, where these parameters are 100% correlated. As \dot{Q} is determined by using a combination of measurement of the electron beam current and CASINO and Monte Carlo simulations, and can be heavily influenced by electron beam shape (in the case of large-apertured electron beams, as discussed above), uncertainties in \dot{Q} are a significant source of error in the analysis. By using a spectrometer to average the frequency-dependent optical response in time, we are summing non-negligible shot noise (from electrons striking the nanowires and from generation/recombination of carriers in the GaN nanowires) over a wide electrical bandwidth. We could further shrink the uncertainty in thermal conductivity in these AC measurements by using a bandpass filter to isolate a small wavelength range near the bandgap CL emission and monitor amplitude modulation in this band *via* lock-in detection during pulsed electron beam excitation, thereby drastically improving signal-to-noise ratio as the bandwidth over which noise is summed with lock-in methods is small.

Comparison of Thermal Conductivities and Methods. The thermal conductivity of bulk GaN at room temperature

reported in the literature is fairly high at 130–220 W/m·K.^{66,67} GaN nanowires previously studied with the suspended microchip method or with photoluminescence have reported thermal conductivity values of 13–19 W/m·K²⁹ for smaller diameter nanowires and <80 W/m·K⁵⁸ for wires of similar diameter to those we studied and are therefore in agreement with our results of 19–68 W/m·K found in this study. Several studies attributed the deviation from the bulk values to decreased phonon mean free path due to large mass-difference scattering from Si impurities.^{29,68,69} One study found additionally that boundary scattering, phonon confinement, and the change in nonequilibrium phonon distribution significantly contributed to the decrease in thermal conductivity in nanowires when compared to bulk.⁶⁹ Si impurities are present in our nanowires, as the nanowires were intentionally doped with Si during growth (see [Methods](#)). The nanoscale thermometry presented here provides avenues for detailed studies of heat flow in confined geometries.

The data shown in [Figure 3d](#) are from the same wires as the data shown in [Figure 4c](#), allowing for direct comparison between the DC slope and AC methods. The extracted thermal conductivities are within error of each other for wires A and B, but not for wire C, although all measurements on all wires show a lower-than-bulk thermal conductivity. The thermal profile for wire C in [Figure 3b](#) should show sections with different slope if there was a deviation in thermal conductivity along its length, but we do not see this to a significant extent. As discussed previously, the wavelength shifts due to doping must be subtracted from the wavelength shifts due to temperature to derive accurate results. If wire C were not completely round as it appears to be in the SEM, our estimate of the cross-sectional area could be inaccurate, leading to lower than expected thermal conductivities with the DC slope method. We did correct for drift in our frequency-dependent measurements, but it is possible that because the doping variation with position is significant at the end of this nanowire, small drifting of the beam caused a much larger effect on the bandgap shift than with more uniformly doped wires A and B. Additionally, a small chip is present at the end of wire C, and so a small amount of drift near the edge of this chip could lead to slightly varying power deposition due to altered electron beam backscatter/transmission/absorption ratios during the measurement, altering results.

Both the DC and AC methods have their advantages and disadvantages. The DC methods allow for easier examination of the heat-sinking quality at the boundaries of the materials during data collection and have higher spatial resolution than the AC method (in our microscope). Additionally, drift during measurements is easier to spot and correct for with the DC method. The DC method is also more sensitive to variations in doping in the wire. With extra large temperature rises, as we saw in the wire used in the DC bridge method, the doping variations played less of a role in determining thermal conductivity, as temperature rises caused much larger bandgap shifts than doping variations did. In the DC slope method with smaller temperature rises, we had to correct for variations in the bandgap emission due to doping (on the order of 1 nm) in the nanowire by extracting bandgap variations along the wire found with low electron beam current. On the other hand, knowledge of the thermal contact resistance was not necessary in the DC slope method, whereas it was critical in the DC bridge method. In fitting the DC data, thermal conductivity is 100% correlated with both electron beam heat flux and wire

cross-sectional area, both of which had the largest sources of uncertainties.

The AC method, as it relies on the electron beam being focused on a single point on the wire, can be collected much faster. In our particular SEM electron column, spatial resolution is worse in the AC method due to changes in the electron beam optics necessary to place the beam into conjugate mode with the focus of the beam between the two blanking plates.⁶⁴ Alternative microscope column designs with optimized beam crossover, which are available commercially, will resolve this issue. In all cases, we assume in our models that thermal conductivity (and wire cross-sectional area) is constant along the wire and not affected by doping; however, it has been shown that thermal conductivity of GaN can decrease with increased doping concentration⁶⁸ (see [Figure S6](#) for discussion). Accuracy could suffer if thermal conductivity is not uniform throughout the wire, as the mathematical model does not account for this (see [Figures S6](#)). In fitting the data, thermal conductivity can be extracted accurately without knowledge of both electron beam heat flux and wire cross-sectional area in the AC method, in contrast to DC methods. The AC method may also suffer less from carrier accumulation in the bandgap, such as blue-shifting caused by the Burnstein–Moss effect.^{70,71} We did not see such an effect in our wires, but it could play more of a role in other materials. In all cases, we assumed heat capacity and density were constant with temperature.

The major drawback of the thermometry method presented here is the strong influence of the localized doping heterogeneity on the bandgap energy. The doping from Si impurities introduced intentionally during growth of the nanowires created ~1 nm variations in the peak bandgap wavelength, which corresponds to a ~50 K equivalent temperature variation. Doping is static (impurities cannot be added or moved), and therefore its influence on the bandgap energy can be separated from temperature changes in a straightforward manner; if the sample temperature is known (no external heating is present and a low electron beam current is used to avoid heating), any variation in peak bandgap in the sample can be attributed to doping. Maximizing accuracy of temperature calibration curves for a given sample can be done with high-resolution low-current mapping of the bandgap shifts of the entire sample at different temperatures of the heating/cooling calibration stage. This allows for definitive separation of the doping background from the temperature shift. In this study, we have measured the calibration curve for a small region of uniform doping on a nanowire and assumed doping would shift the curve offset but not the slope, which was observed to be a reasonable assumption previously.⁴² [Figure 3g](#) shows the bandgap variation due to doping in wires A, B, and C (the CL yield from the wire in [Figures 2](#) and [3a](#) was too low for our spectrometer to detect without a current large enough to heat the nanowire).

A modification of the AC method can be used to measure thermal conductivity without need for a calibration curve with a few assumptions. First, a low current scan must be taken to determine the peak bandgap without heating. Next, it can be assumed that the temperature scales linearly with bandgap shift, which is valid over small temperature ranges. Finally, the data can be normalized and fit with the nondimensionalized version of [eq 5](#) given in the [Supporting Information](#) in order to extract the thermal conductivity. In short, the peak wavelength data can directly be fit to extract the thermal conductivity

instead of first converting to temperature, eliminating the need for a calibration curve.

CONCLUSIONS

We have presented a method of cathodoluminescence nanothermometry for semiconductors along with three different methods for using this thermometry method to measure thermal conductivity of GaN (or other semiconductor) nanowires. CL thermometry can be used with very low currents in order to measure temperatures *in situ* without heating the sample, or it can be used with high currents to act additionally as a delta-function-like heat source to study thermal transport. We additionally showed that, alongside GaN, both Si and GaAs exhibit shifts in CL bandgap emission with temperature, indicating that the temperature mapping and thermal transport measurements examined here are broadly applicable to other semiconductors and could find uses in examining integrated circuits *in situ* to find defects, for example. The thermal conductivity measurement methods explored here are fairly rapid and have low fabrication requirements. The existing framework for laser-based pump–probe measurements of thermal conductivity, like time-domain thermoreflectance, could easily be translated into the SEM using CL nanothermometry, which could result in 100× better spatial resolution than these state-of-the-art methods.³² Additionally, the tunability of the penetration depth of electrons (between 10s of nanometers and microns in SEMs, controlled by the electron energy) creates possibilities for heat transport studies in nanolayers currently inaccessible in photon-based studies. Because of the high resolution, high scan speeds, and high level of control an SEM offers, CL nanothermometry-based methods offer an enticing framework in which to study phonon dynamics, ballistic transport, and near-field heat transport phenomena hitherto unmeasurable.

METHODS/EXPERIMENTAL

Nanowire Fabrication. The nanowire fabrication process using a top-down approach combining displacement Talbot lithography and selective area sublimation has been detailed previously.⁴⁹ A GaN layer was grown by metalorganic-vapor-phase epitaxy on *c*-plane (0001) sapphire substrates starting with a 2 μm undoped GaN layer followed by 5 μm of Si-doped ($5 \times 10^{18} \text{ cm}^{-3}$) GaN. A 60 nm thick Si_xN_y deposited by plasma-enhanced chemical vapor deposition on top of the GaN layer was patterned with displacement Talbot lithography to get a hexagonal array of nanodisks (diameter of 515 nm) with a pitch of 1.5 μm.⁷² The sample then underwent selective area sublimation between 900 and 920 °C in a molecular beam epitaxy chamber for 8 h in order to define the 7 μm nanowires. The Si_xN_y mask was etched using a HF-based solution. Some wires shown in this article are slightly shorter than 7 μm due to breaking when separated from the growth substrate or variations in the sublimation rate due to the temperature gradient between the center and the edge of the wafer.

ASSOCIATED CONTENT

Supporting Information

The Supporting Information is available free of charge at <https://pubs.acs.org/doi/10.1021/acsnano.1c00850>.

Nanowire damage analysis; Monte Carlo simulations; peak wavelength *versus* temperature calibration curves; doping effects on peak wavelength; frequency roll-off of beam blanker; thermal modal calculations; varied electron beam current temperature response with frequency (PDF)

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Author Contributions

K.M., A.P., and S.M. conceived the experiment, B.D., P.C., S.V., and P.S. fabricated the nanowires, K.M. measured the data, K.M. analyzed the data, S.M., M.S.G., M.L., and K.M. built the measurement systems, and all authors contributed to the manuscript.

Notes

The authors declare the following competing financial interest(s): A.P. is co-founder and co-owner of Delmic BV, a company that produces the cathodoluminescence system that was used in this work.

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